

Assembly and Photocarrier Dynamics of Heterostructured Nanocomposite Photoanodes from Multicomponent Colloidal Nanocrystals

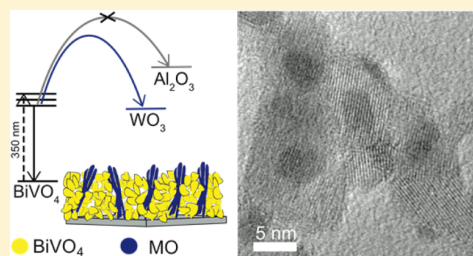
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S Supporting Information

ABSTRACT: Multicomponent oxides and their heterostructures are rapidly emerging as promising light absorbers to drive oxidative chemistry. To fully exploit their functionality, precise tuning of their composition and structure is crucial. Here, we report a novel solution-based route to nanostructured bismuth vanadate (BiVO₄) that facilitates the assembly of BiVO₄/metal oxide (TiO₂, WO₃, and Al₂O₃) nanocomposites in which the morphology of the metal oxide building blocks is finely tailored. The combination of transient absorption spectroscopy—spanning from picoseconds to second time scales—and photoelectrochemical measurements reveals that the achieved structural tunability is key to understanding and directing charge separation, transport, and efficiency in these complex oxide heterostructured films.

KEYWORDS: Colloidal synthesis, ternary oxides, assembly, photoelectrochemistry, charge dynamics



Achieving fine control over the composition and stoichiometry of multicomponent oxide materials is a nontrivial, yet technologically important, challenge that has significant implications for a number of applications, including batteries, smart windows, fuel cells, and resistive switching memories.^{1–4} In the context of solar-to-chemical energy conversion, complex oxides are receiving increasing attention as photocatalysts to drive oxidative chemical reactions, and in particular water oxidation, since they exhibit relatively high stability under oxidative and corrosive conditions.^{5,6} Oxides containing d⁰ (e.g., Ti(IV), V(V), W(VI)) and s² (e.g., Sn(II), Bi(III), Sb(III)) elements have resulted in a class of promising visible light absorbing photoanodes, including the well-studied BiVO₄ and less explored systems such as Bi₂WO₆, SnWO₄, and SnNb₂O₆.^{7–12} However, the performance criteria for photoanodes are complex and difficult to meet in any one material. Hence, heterojunction architectures have been developed to take advantage of favorable properties of two different oxide materials, while also overcoming their deficiencies. Specifically, smaller band gap materials, such as Fe₂O₃ or BiVO₄, exhibit increased light absorption in the visible spectrum, but their performance losses are generally attributed to a short photocarrier lifetime (Fe₂O₃) and limited photoexcited electron mobility and conductivity (Fe₂O₃ and BiVO₄).^{13–22} Meanwhile, larger band gap metal oxides (MO), such as TiO₂, ZnO, or WO₃, may have improved mobility but reduced visible light absorption. Therefore, combining smaller band gap and larger band gap metal oxides in heterostructures (i.e., Fe₂O₃/WO₃, BiVO₄/TiO₂, BiVO₄/WO₃) has been shown to enhance the

water oxidation photocurrent.^{13–22} To cite one of the most recent examples, Shi et al. have demonstrated that W, Mo-codoped BiVO₄-decorated WO₃ helical nanostructures exhibit among the highest photocurrent densities to date for BiVO₄-based photoanodes, specifically 5.35 mA/cm² at the reversible water oxidation potential of 1.23 V versus reversible hydrogen electrode (RHE), after catalyst deposition.²¹ This enhancement was attributed to a combination of effective light scattering, improved charge separation and transport, and an enlarged interfacial contact area with the electrolyte.

The performance enhancements achieved in oxide heterostructures are not only strongly dependent on light absorber composition, but also on structural parameters, such as characteristic size, shape, and the relative arrangement of the two components.^{13–27} Opposing structural modifications are often required to improve one parameter at the cost of another. For example, a large interfacial area at the heterojunction, obtained by nanostructuring, is advantageous for charge separation but can be detrimental for charge transport, which would benefit from a more extended crystalline network.^{13–27} When aiming at maximizing photoelectrochemical (PEC) performance, the ability to tailor-make material platforms with tunable morphological characteristics in an unrestricted compositional range is critical for achieving optimal design specifications, as well as for providing understanding of the sensitivities of performance parameters to different composi-

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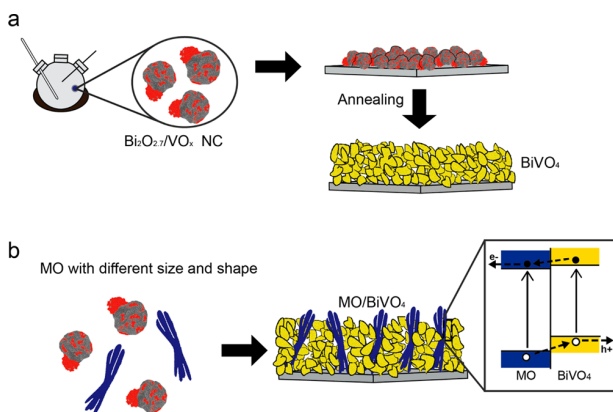
tional and structural parameters. Although they have led to significant advances in the field, the previously reported systems do not yet possess the broad synthetic tunability required to systematically probe the important roles of structure and composition on photocarrier transport in multicomponent oxide heterostructures.

Our approach to gain structural and compositional control is to synthesize and assemble colloidal nanocrystals (NCs), a strategy that has been fruitful in recent years for addressing similar scientific needs in other technological areas.^{28–33} The superior control afforded by colloidal chemistry, including composition, size, and shape, combined with solution processability and rich surface chemistry, has provided access to modular inorganic nanocomposites with an unprecedented tunability.^{2,28–33} Nonetheless, the full potential of colloidal chemistry has not yet been explored to construct complex functional 3D architectures for solar-to-chemical energy conversion.

One of the hurdles to realizing oxide heterojunctions suitable for PEC with tailored structure and composition by NC assembly is the lack of colloidal approaches for the synthesis of ternary and quaternary oxide light absorbers. While well-established colloidal routes exist for complex multielement chalcogenides (e.g., CuZnSSe, PbSeSe, PbSeTe), which have been widely used for ink-based photovoltaics, the synthesis of ternary and quaternary oxide NCs still remains to be fully explored.^{34–38}

In this work, first a colloidal synthetic strategy to access monoclinic BiVO₄ nanostructured thin film photoanodes is described. Specifically, Bi₂O_{2.7}/VO_x NC heterodimers were synthesized, and their thermal evolution into BiVO₄ films was followed by X-ray diffraction and optical spectroscopy. Second, the heterodimers were assembled with presynthesized TiO₂, WO₃, and Al₂O₃ NCs with different sizes and shapes to fabricate heterostructured nanocomposites, achieving unprecedented structural tunability compared with previous work (Scheme 1).^{13–22} Due to the favorable energetics for selective extraction of photoexcited electrons from BiVO₄ to WO₃, the impact of the nanostructure on PEC performance, as well as photocarrier separation, recombination, and extraction, was specifically investigated for the case of BiVO₄/WO₃ nanocomposite heterostructures.

Scheme 1. Schematic Representation of the Novel Colloidal-Based Approach to MO Heterostructured Photoanodes Developed in This Work



Synthesis of Bi₂O_{2.7}/VO_x NC Heterodimers and Their Thermal Evolution into Nanostructured BiVO₄ Films.

Organic-capped Bi₂O_{2.7}/VO_x NC heterodimers were synthesized through an in situ seed-mediated growth, where Bi nanosheets generated in the reaction flask (see Figure S1) act as seeds for the nucleation of a noncentrosymmetric vanadium oxide shell. Bismuth chloride (BiCl₃) was used as a bismuth precursor and vanadyl acetylacetonate (VO(acac)₂) as a vanadium source, while oleylamine was used as surfactant and solvent (see SI for experimental details). BiCl₃ was reduced to elemental bismuth in the form of nanosheets by the amine. After reaction of the Bi nanosheets with VO(acac)₂, Bi₂O_{2.7}/VO_x NC heterodimers were precipitated and redispersed in hexane. Similar results, with a lower product yield, were obtained when the bismuth and vanadium precursors were introduced simultaneously at the beginning of the synthesis (Figure S2). Transmission electron microscopy (TEM) and high-angle annular dark field scanning TEM (HAADF-STEM) images at different magnification (Figure 1a,b and insets)

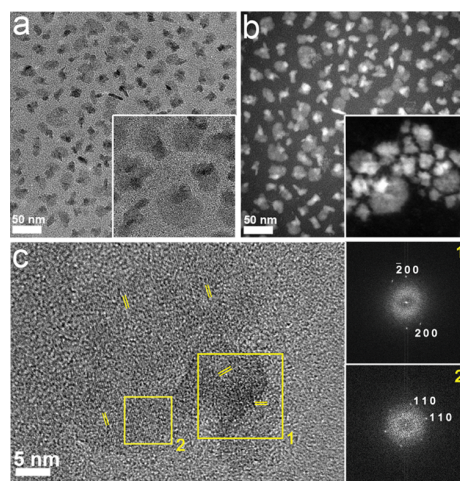


Figure 1. (a) Low-resolution TEM and (b) STEM-HAADF images of as-synthesized Bi₂O_{2.7}/VO_x NC heterodimers; (c) HRTEM image of a single heterodimer, along with the FFTs from the corresponding regions enclosed by labeled yellow boxes (right).

showed uniformly dispersed NCs, with an average size of 25 ± 4 nm, comprised of two domains arranged in a nonconcentric dimer-like topology. High-resolution TEM (HRTEM) analysis (Figure 1c) elucidated the nature of the two differently contrasted regions in the heterodimers. As shown in Figure 1c, the darker domain is fully crystalline while the lower contrast domain is composed of smaller crystalline domains embedded in an amorphous matrix. The *d*-spacing of the lattice fringes in the crystalline domain, as derived from fast Fourier transform (FFT) analysis (insets in Figure 1c), were equal to $d = 2.0$ Å and $d = 2.6$ Å, which correspond closely to the (2 0 0) [$d_{200} = 1.9$ Å] and (1 1 0) [$d_{110} = 2.7$ Å] planes of the Bi₂O_{2.7} tetragonal crystal structure (PDF No. 30-065-4028). STEM-energy dispersive X-ray spectroscopy (EDS) analysis on single NCs revealed the presence of both bismuth and vanadium within the NC heterodimers (see Figure S3).

The existence of crystalline domains of Bi₂O_{2.7} in the heterodimers was confirmed also by X-ray diffraction (XRD) analysis. The XRD pattern of the as-deposited NCs (Figure 2a, black line) showed two broad peaks at $2\theta = 32.9^\circ$ and 47.1° ,

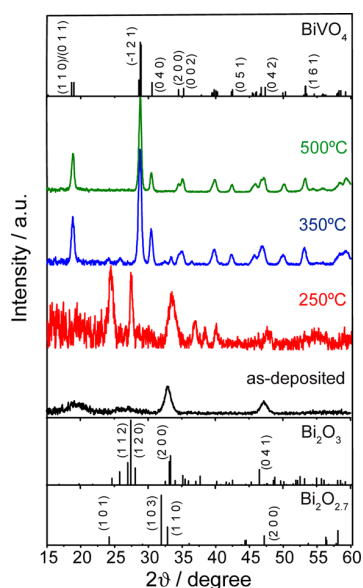


Figure 2. XRD patterns of the NC film as-deposited (black line), annealed at 250 °C for 2 h (red line), at 350 °C for 2 h (blue line), and at 500 °C for 10 min (green line).

ascribable to the $\text{Bi}_2\text{O}_{2.7}$ tetragonal crystal structure (JCPDS No. 03-065-4028). Scherrer analysis performed on the peak at $2\theta = 47.1^\circ$ revealed an average crystallite size of ~ 10 nm, consistent with the size of the fully crystalline domains observed in the TEM images. Structural refinement through Rietveld analysis was hindered by the low intensity and broadness of the XRD peaks. Therefore, positive identification of the broad hump at lower 2θ was not possible.

Inductively coupled plasma optical emission spectroscopy (ICP-OES) analysis revealed that the NC heterodimers contained bismuth and vanadium with a molar ratio Bi:V of 1:1.4, corresponding to a vanadium-rich composition. X-ray photoelectron spectroscopy (XPS) analysis yielded the same Bi to V molar ratio and an oxidation state of +3 and +5 for bismuth and vanadium, respectively (Figure S4 a,b). While both HRTEM and XRD identified $\text{Bi}_2\text{O}_{2.7}$ as the main phase in the crystalline domains, the combination of ICP, XPS, and STEM-EDS results suggests that the composition of the lower contrast domains in the TEM images likely corresponds to vanadium oxide (VO_x) or to a Bi–V–O compound. This hypothesis of formation of amorphous VO_x or Bi–V–O nanosize domains is consistent with previous reports.^{39,40} The existence of many stable VO_x polymorphs and of additional metastable phases, especially at the nanoscale, accounts for the difficulty to crystallize VO_x nanoparticles or to identify their structure when crystalline.⁴⁰ With regard to the Bi–V–O compound, Choi et al. assigned their poorly crystalline films to $\text{Bi}_4\text{V}_6\text{O}_{21}$, one stable phase in the Bi–V–O family composed of Bi(III) and V(V); however, we cannot definitively confirm or exclude its presence in our system.⁸

To form functional semiconductor thin films, the as-synthesized $\text{Bi}_2\text{O}_{2.7}/\text{VO}_x$ NC heterodimers were spin-coated on silicon substrates and annealed at different temperatures, and the resulting changes in crystal structure were recorded by XRD. As shown in Figure 2, after annealing at 250 °C for 2 h in air, new peaks at $2\theta = 24.2^\circ$, 27.3° , 36.3° , 37.1° , and 39.5° appeared with respect to the as-deposited sample. Most of these

new peaks were in good accordance with the XRD pattern of monoclinic Bi_2O_3 (JCPDS No. 04-005-4873), suggesting that during the annealing step at 250 °C, oxygen is incorporated in the tetragonal nonstoichiometric $\text{Bi}_2\text{O}_{2.7}$ lattice (JCPDS No. 30-065-4028). As the annealing temperature was increased to 350 °C, the film crystallized into the monoclinic BiVO_4 phase, as evidenced by the appearance of intense peaks at $2\theta = 29^\circ$, 31° . However, an impurity phase was still present (i.e., $2\theta = 33^\circ$), suggesting that a higher temperature is required to complete the transformation. After annealing for 10 min at 500 °C in air, the film crystallized into pure monoclinic BiVO_4 phase (JCPDS No. 00-014-0688), and the narrowing of the peaks indicated an increase of the film grain size up to ~ 80 nm (~ 30 nm for the films annealed at 350 °C) that is evident also in the SEM images (Figure S5). XPS and Raman spectroscopy data were also consistent with the assigned annealing-induced phase transformations (Figure S4). The importance of the presence of Bi, V, and O within the same NC building blocks was evidenced by the failure to obtain monoclinic BiVO_4 films when separately synthesized and purified Bi NCs were reacted with the vanadium precursor (Figure S6).

It is important to note that, although XRD analysis for the discussed reaction conditions indicated the presence of the pure BiVO_4 phase in samples annealed at 500 °C, Raman spectroscopy revealed that amorphous V_2O_5 is also present (Figure S4c). This finding was not surprising considering the vanadium-rich composition of the heterodimers measured by ICP-OES analysis. For samples prepared with a lower concentration of the bismuth precursor in the reaction mixture, V_2O_5 was clearly detected by XRD after annealing (Figure S7). With higher concentration of bismuth precursor, a major fraction of the sample was instead composed of 300 nm Bi spheres (Figure S8). As previously reported, immersing the films in 1 M NaOH solution for 30 s was sufficient to selectively remove V_2O_5 (see Table S1).⁷ The phase transformation $\text{Bi}_2\text{O}_{2.7}/\text{VO}_x \rightarrow \text{Bi}_2\text{O}_3/\text{VO}_x \rightarrow \text{BiVO}_4$ was also monitored by UV–vis absorption spectroscopy (see Figure S9 and S10), and the data were consistent with the results obtained by XRD.

Transient absorption (TA) spectroscopy was utilized to study the excited state dynamics of the nanostructured BiVO_4 films as a function of sample annealing temperatures of 350 and 500 °C. Long-lived photoexcited charge carriers are often associated with enhanced PEC performance of photoelectrodes. Longer photocarrier lifetimes generally correspond to reduced recombination rates, which compete directly with charge transfer to drive the desired redox reaction, such as water oxidation in the present case.^{41–43} TA measurements offer an opportunity to examine the role of carrier surface trapping, expected due to the nanostructured nature of the material, and crystallinity on the excited state lifetime. The time dependence of the normalized transient differential absorption (dA) recovery, and the results of multiexponential fitting analysis are shown in Figure 3. For the 350 °C (500 °C) annealed sample, the extracted lifetimes were 1.4, 7.0, and 40 ns (2.7, 11, and 100 ns). Henceforth, these three components will be referred to as “fast”, “medium”, and “slow”, respectively. In general, the sample annealed at 500 °C exhibited a similar fast and medium component but significantly increased lifetimes from the slow component, compared to the sample annealed at 350 °C. The normalized amplitudes of these three components provide additional information regarding the origin of these lifetimes. The amplitudes of the fast, medium, and slow

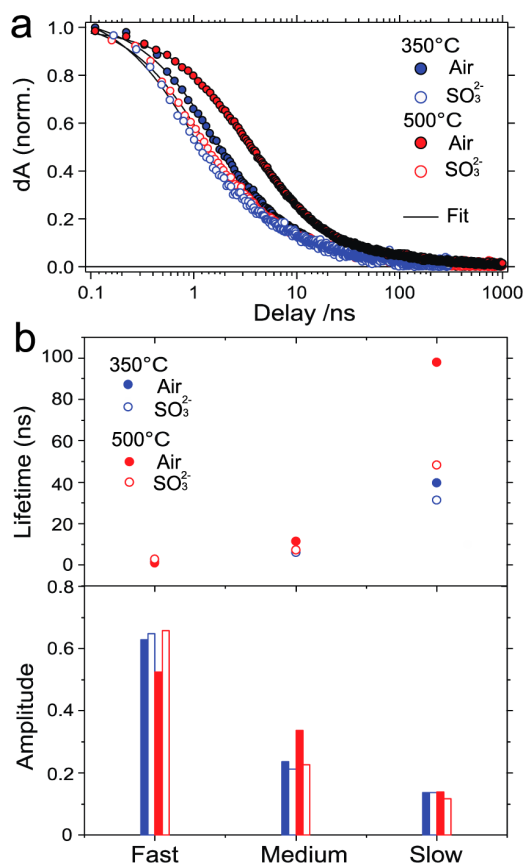


Figure 3. (a) Transient absorption decay response (excitation pulse $\lambda = 350$ nm, transient signal between 450 and 495 nm) of BiVO₄ annealed at 350 and 500 °C collected in air and submerged in 1 M potassium phosphate buffer (pH = 6.8) with 0.1 M Na₂SO₃, along with the kinetic model fits using eq S1. (b) Fit parameters showing the extracted lifetimes (top) and the normalized initial amplitudes (bottom) of the fast, medium, and slow components, where $A_{\text{fast}} + A_{\text{medium}} + A_{\text{slow}} = 1$. The slow component-stretching factor was 0.5.

components for the samples annealed at 350 °C (500 °C) were 0.63, 0.24, and 0.14 (0.52, 0.34, and 0.14). By increasing the annealing temperature, the amplitude of the fast component decreased relative to that of the medium component, whereas the slow component remained the same. Given the increased crystalline order and grain size observed with 500 °C annealing, we correlate the fast component with rapid carrier recombination at internal defect sites, whose concentrations can be reduced through annealing. At longer times, corresponding to the medium component, a second bulk recombination pathway dominates the observed dynamic relaxation. As the fast recombination channel is eliminated, the relative contribution from the medium component, which appears to be less affected by annealing, increases. Recently, Ravensbergen et al. demonstrated that recombination of trapped carriers occurs between 10 ns and 10 μ s.⁴⁴ As discussed below, we also attribute the slow component observed here to be due to trap state-mediated recombination, in the present case at the surfaces of nanocrystalline BiVO₄.

To further examine the role of the surface in these samples and correlate the TA dynamics with the PEC performance, samples annealed at 350 and 500 °C were immersed in a 0.1 M sodium sulfite solution (a hole scavenger). In such a solution,

upward band bending of both valence and conduction bands at the semiconductor solution interface is expected. Consequently, electron–hole separation should be increased, with holes preferentially drifting toward the surface in the presence of the electric field below the semiconductor/electrolyte junction.^{45,46} While a similar field may exist for the case of BiVO₄ in air, hole transfer to sodium sulfite in solution reduces the instantaneous concentrations of accumulated holes near the surface. The relaxation dynamics of both types of samples, shown in Figure 3a, were accelerated in the electrolyte compared to in air, with lifetimes of 0.9, 6.1, and 30 ns for the sample annealed at 350 °C and 1.1, 7, and 50 ns for the sample annealed at 500 °C, as shown in the top panel of Figure 3b. Consistent with their assignment as bulk recombination pathways, the fast and medium components were only slightly affected by the environment. However, the longer lifetime was significantly reduced by the introduction of an additional recombination route corresponding to the transfer of photoholes to solution. This is especially evident in the sample annealed at 500 °C, where the improved sample quality is likely to have improved the surface and near-surface region of the semiconductor, therefore favoring charge transfer. These results support the conclusion that the surface and near-surface region of the nanostructured BiVO₄ thin films play important roles on recombination dynamics of long-lived excited states. The longer carrier lifetimes, which aid in improving efficiency for driving oxidation reactions in solution, are enabled by the lower defect concentrations and result in increased photocurrent densities, as described below.

To evaluate the PEC performance, the BiVO₄ films annealed at 350 and 500 °C (~ 200 nm thickness) were prepared as photoelectrodes on FTO glass substrates and the current density–voltage (J – E) curves are reported in Figure S11. The photocurrent densities were 0.5 mA cm^{−2} and 0.8 mA cm^{−2} at 1.23 V vs RHE for the samples annealed at 350 and 500 °C, respectively. The higher photocurrent density measured for the 500 °C sample is consistent with the observation of longer relaxation times and reduced carrier trapping compared with the sample annealed at lower temperature. It is important to note that, while these photocurrent values are lower than state-of-art BiVO₄-based photoanodes, undoped BiVO₄ is commonly reported with photocurrent densities around 1 mA cm^{−2} at 1.23 V vs RHE.^{8,47,48}

BiVO₄ has a relatively low majority electron mobility compared to other metal oxide materials.^{44–46,49} For bulk BiVO₄ materials, where a larger fraction of the photoelectrons decay through the ~ 40 ns bulk channel, the diffusion lengths remain longer (~ 100 nm in bulk material).^{7,50} Herein, when coupled with the large fraction of short lifetime pathways due to the large surface to volume ratio, the majority carrier diffusion lengths are likely to be decreased and extraction of electrons to the back contact may limit the achievable photocurrent density. This observation provides a strong impetus to couple the nanostructured BiVO₄ light absorber to a secondary nanostructured metal oxide material that possesses improved electron transport properties in order to mitigate the limitations arising from short majority carrier diffusion lengths. If materials possessing appropriate band alignment are utilized, formation of a solid state bulk heterojunction nanocomposite is expected to improve electron charge extraction efficiency and, consequently, overall photoelectrochemical performance.

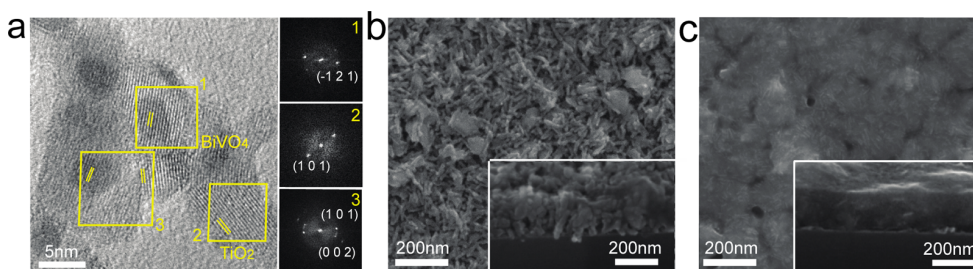


Figure 4. (a) HR-TEM image of BiVO₄/TiO₂-big nanocomposite, along with the FFTs from the corresponding regions enclosed by labeled yellow boxes (right). (b) and (c) SEM images on the surface and in cross-section (inset) of the BiVO₄/TiO₂-big and BiVO₄/WO₃-big nanocomposites, respectively.

Assembly of BiVO₄/MO Heterostructured Nanocomposites. To demonstrate and explore the unprecedented tunability afforded by our novel colloidal-based approach to MO heterostructured photoanodes, we have chosen BiVO₄/WO₃, BiVO₄/TiO₂ and BiVO₄/Al₂O₃ bulk heterojunctions as representative examples. Among BiVO₄ heterojunction systems, BiVO₄/WO₃ has been the most studied system so far, typically in planar thin film form or in nanowire arrays with length in the micron-scale range.^{19–27} The band alignment between these two oxides favors electron transfer from the conduction band of BiVO₄ to that of WO₃, while also preventing hole transfer from the valence band of BiVO₄ to that of WO₃. Therefore, such heterojunctions promote charge separation and inhibit recombination.^{19–27} In contrast, measurements of band positions of bulk TiO₂ and BiVO₄ suggest that the conduction band of TiO₂ lies slightly above that of BiVO₄ in energy; yet, increases of photocurrent density have been recorded from BiVO₄/TiO₂ nanocomposites when compared to pure BiVO₄.^{17,18} In this case, the transfer of high-energy electrons, photoexcited above the band edge, from the BiVO₄ to the TiO₂ conduction band has been suggested.^{17,18} Finally, Al₂O₃ presents a large energy barrier for transfer of both electrons and holes and no additional charge separation at the interface is expected. Therefore, this materials system represents a valuable reference in the TA measurements that will be described in the following section.

In the present work, we have fabricated BiVO₄/MO nanocomposites by spin-coating hexane solutions containing the Bi₂O_{2.7}/VO_x NC heterodimers mixed in different ratios with hexagonal WO₃, anatase TiO₂, and Al₂O₃ NCs of various size and shape (Figure S12). Specifically, WO₃ linear nanorods with two different aspect ratio (5 × 10 nm and 5 × 60 nm, WO₃-small and WO₃-big, respectively), TiO₂ linear nanorods (4 × 16 nm, TiO₂-small) and branched nanorods (TiO₂-big), and quasi-spherical Al₂O₃ NCs were examined (see Supporting Information for experimental details). After annealing the heterodimer/MO thin films in air at 500 °C for only 10 min, monoclinic BiVO₄ was formed and the MO morphology was preserved, as evidenced by XRD (Figure S13). No apparent peak shift of the monoclinic BiVO₄, which would indicate Ti- or W- bulk doping or alloying, was observed in the XRD patterns of the composites.¹⁹ Because of the use of precrystallized building blocks, our annealing time is much shorter compared to other methods.^{7,21} To cite one example, 11 hours of annealing at 500 °C was required for the case of the W, Mo-doped BiVO₄/WO₃ helix nanostructures.²¹

The different processing conditions reported here likely account for the limited interdiffusion of the elements across the BiVO₄/MO interface and thus explains the absence of high

doping levels that have been observed in previously reported heterostructured architectures. Figure 4a shows a representative HR-TEM image of BiVO₄/TiO₂-big nanocomposites, together with selected area FFTs, that reveals the existence of an intimate contact between the TiO₂ and the BiVO₄ domains. SEM images of BiVO₄/WO₃-big, BiVO₄/TiO₂-big, and BiVO₄/Al₂O₃ nanocomposites (50/50 w/w), shown in Figure 4b,c and in the Supporting Information (Figure S14), reveal a uniform distribution of the MO NCs within the BiVO₄ films. In agreement with the XRD data, the initial MO morphology is largely preserved and the BiVO₄ morphology and grain size in the nanocomposites are equivalent to the pure BiVO₄ films (Figure S5). The UV–vis absorption spectra of the nanocomposites reported in Figure S15 revealed a composition-dependent absorption band edge in agreement with previous work.^{21,24}

PEC and TA studies of BiVO₄/WO₃ heterostructured nanocomposites. Following the assembly of the BiVO₄/MO heterojunctions, we utilized these nanocomposites as platforms for understanding the roles of structure and composition on charge separation, transport, and photoelectrochemical performance in bulk heterojunction photoanodes. The conduction band (CB) level of WO₃ lies energetically lower than that of BiVO₄ and photoinduced electron transfer from BiVO₄ to WO₃ should be possible. At the same time, the valence band (VB) level of WO₃ lies significantly lower in energy than that of BiVO₄ and no photoinduced hole transfer is expected.^{19–27} Thus, WO₃ should provide an electron selective charge extraction interface. Because of this favorable energetic alignment for selective electron extraction from BiVO₄, the BiVO₄/WO₃ materials system is ideal for probing the role of nanocomposite structure on charge separation and transport via PEC and TA measurements. Trends in PEC characteristics and correlations with photocarrier dynamics provide important insights that can guide future developments of such nanocomposites and allow verification of our novel approach. We also note that prior experiments on BiVO₄/TiO₂ interfaces have suggested the possibility of selective electron transfer, despite the observation that the CB of single crystalline TiO₂ lies ~0.4 eV above the CB of BiVO₄.^{17,18} While preliminary results from our BiVO₄/TiO₂ nanocomposites also suggest the possibility for selective charge transfer, unravelling potentially nontraditional injection mechanisms, such as hot carrier transfer, within complex metal oxide composites introduces considerable uncertainty in interpretation and will be addressed in a future contribution.

The PEC performance characteristics of the nanocomposites were evaluated by measuring J-E curves and incident-photon-to-current efficiency (IPCE) (Figure S6a,b). Measurements were

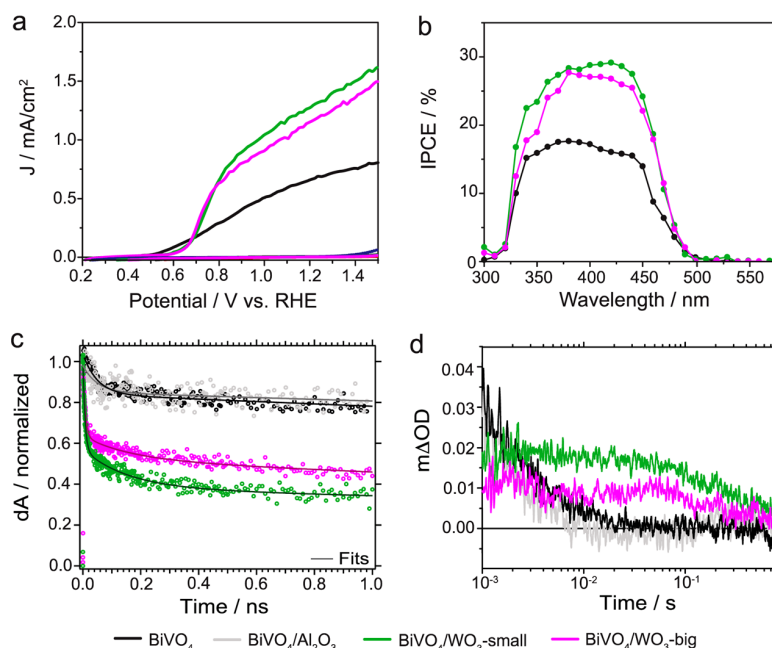


Figure 5. (a) Current density vs potential (J-E) curves of photoelectrodes prepared from the different nanocomposites measured under illumination (continuous traces) and in dark (dashed traces) in a 1 M phosphate buffer (pH 6.8) containing 0.1 M Na₂SO₃ as hole scavenger and (b) incident photon-to-current efficiency (IPCE) measured at 1.23 V vs RHE. (c) Transient absorption decay response in the ps time scale (excitation pulse $\lambda = 350$ nm, transient signal probed at 475 nm) of different nanocomposites compared with the pure BiVO₄ thin film. (d) Transient absorption decay traces of different nanocomposites in the ms time scale (excitation pulse $\lambda = 355$ nm, transient signal probed at 550 nm).

conducted on samples with 50/50 w/w BiVO₄/WO₃ composition under AM 1.5G simulated solar irradiation and in the presence of 0.1 M Na₂SO₃ as a hole scavenger. The presence of hole scavenger in solution enables determination of the inherent performance of these thin film light absorbers without convoluting the potentially variable catalytic activities of their surfaces or needing to incorporate, a separate water oxidation catalyst, which is beyond the scope of this work. The J-E curves in Figure 5a show that all BiVO₄/WO₃ nanocomposites approximately double the photocurrent density relative to the pure BiVO₄ film. At 1.23 V vs RHE, photocurrent densities of 0.68, 1.20, and 1.32 mAcm⁻² were measured for pure BiVO₄, BiVO₄/WO₃-big, and BiVO₄/WO₃-small, respectively. Thus, an approximately 2× enhancement of the current density in the nanocomposites with respect to the pure BiVO₄ was observed. Moreover, the small WO₃ nanorods lead to an enhanced charge separation efficiency of 14% compared with the big WO₃ nanorods (see details in the Supporting Information). In agreement with the J-E curves, the IPCE at 1.23 V vs RHE shows an approximately doubling of efficiency in the nanocomposites, with the highest IPCE values achieved in the BiVO₄/WO₃-small nanocomposites (30% at 430 nm). The result of smaller size WO₃ outperforming more extended crystals contrasts with previous work on BiVO₄/WO₃ heterojunctions where superior PEC performance were achieved by integrating longer WO₃ nanowires possessing intrinsically improved charge transport properties.^{19,21,24} This observation indicates that in our case charge transport in the MO domain is not the main parameter governing the photocurrent in the nanocomposites.

TA spectroscopy was utilized to obtain insight into the excited state dynamics and to elucidate the PEC data. Figure 5c shows representative relaxation dynamics of pure BiVO₄ compared to BiVO₄/WO₃ and BiVO₄/Al₂O₃ heterostructures,

probed above the fundamental bandgap and on the ps time scale. Since Al₂O₃ presents a large energy barrier for transfer of both electrons and holes, BiVO₄/Al₂O₃ nanocomposites were used as a reference. Photocarrier relaxation characteristics are found to be nearly identical for pure BiVO₄ and BiVO₄/Al₂O₃ films (Table S2), consistent with the expectation that no charge transfer should occur at the interface between the semiconductor and the insulator. Furthermore, this reference measurement suggests that processing of BiVO₄/MO nanocomposites does not inherently introduce additional electronically active surface and interface states and does not modify the BiVO₄ morphology.

In the BiVO₄/WO₃ nanocomposites, an additional fast component is observed in the transient excited state response. At the probed energy, just above the bandgap, the signal arises from the photoexcited state of BiVO₄. Therefore, additional charge recombination or transfer channels will result in faster relaxation from the excited state and accelerate the decay of the transient signal. In the present case, electron transfer from BiVO₄ to WO₃ provides an additional decay channel and results in electron depopulation from the BiVO₄. Multiexponential fitting reveals that these fast electron transfer processes are characterized by time constants of 7 ± 1 ps (50 ps for pure BiVO₄ and BiVO₄/Al₂O₃). While there was no significant difference in the observed rate of electron transfer between the WO₃ small and big samples, the amplitudes of these decay components differed with structure. This component contributed to 35% for WO₃-big and 42% for WO₃-small. It is worth to noting that the relative difference between these two values (17%) is comparable with the charge separation efficiency extracted by the PEC measurements (14%). This implies that the efficiency of photogenerated electron injection across the heterojunction interface was higher for the case of the smaller WO₃ nanorods.

While the decay of the photoexcited state of BiVO_4 at the picosecond time scale is observed by probing above its bandgap, the associated electron transfer across the heterojunction interface does not correspond to relaxation to the ground state. Indeed, it is expected that charge transfer across the heterojunction interface will significantly increase photo-carrier lifetimes due to the spatial separation of electrons and holes. It has been previously shown that the transient absorption response of BiVO_4 in the spectral range below its bandgap originates from photoexcited holes in the material.³⁶ Therefore, to better understand the role of the MO in charge separation efficiency and to probe the influence of the charge separation on long-lived photoholes, which are important for water oxidation, TA spectroscopy was performed in the millisecond to second time scale at a probe wavelength of 550 nm. As shown in Figure 5d, the transient absorption characteristics for the pure BiVO_4 and $\text{BiVO}_4/\text{Al}_2\text{O}_3$ nanocomposites are nearly identical, with decay to the ground state occurring within approximately 10 ms. In stark contrast, a residual transient absorption is still observed after ~ 1 s in the WO_3 -based nanocomposites, thus indicating the presence of long-lived photoexcited hole states in these heterojunction systems. We note that no transient absorption signal was observed for the WO_3 alone (data not shown). The observation of long-lived photohole-related states can be attributed to the suppression of recombination due to the separation of photogenerated holes and electrons in BiVO_4 and WO_3 , respectively.

TA measurements revealed electron injection from BiVO_4 to WO_3 , which is consistent with the band alignment of the two MOs. Importantly, a higher efficiency of electron injection in the WO_3 -small versus WO_3 -big was observed. These data help to elucidate the higher performance of $\text{BiVO}_4/\text{WO}_3$ -small by indicating that efficient charge separation is key to maximizing the PEC performance; once the electrons are injected into WO_3 , charge transport is sufficiently good to not limit overall performance. Improved efficiency of electron injection, likely deriving from a more extended interfacial area between BiVO_4 and WO_3 in the case of WO_3 -small, is thus the relevant parameter for enhancing the photocurrent in the PEC measurements. Optimization of the interface is expected to largely benefit the overall PEC performance in this class of MO photoanode heterojunctions.

The structural tunability afforded by the NC-based architectures, together with combined PEC and TA measurements, allow for important insights into the relative roles of charge separation at the interface and charge transport in the MO, which can each play crucial roles in nanoscale composites. Future in situ optical studies would be helpful to gain further knowledge about the bias-dependent charge dynamics in these nanocomposite photoanodes.^{45,51}

In summary, an in situ seed-mediated growth method for the synthesis of colloidal $\text{Bi}_2\text{O}_{2.7}/\text{VO}_x$ NC heterodimers has been developed. The as-prepared NCs were dispersible in a colloidal stable solution that was then used as precursor ink for the growth of BiVO_4 films upon annealing. This novel ink-based route to constructing BiVO_4 photoanodes shows unique promise in designing more complex and optimized photoanodes. BiVO_4/MO nanocomposites were assembled, and the MO domain size, shape, and composition were varied. Studies of excited state dynamics from the picosecond to the second time domain provided insight into charge injection across the $\text{BiVO}_4/\text{WO}_3$ interface, which results in improved PEC

performance by mitigating low majority carrier diffusion lengths in BiVO_4 , while also increasing the photohole lifetime in the nanostructured BiVO_4 . These results highlight the significant potential afforded by assembly of such oxide nanocomposites and unveil relationships between MO properties and PEC performance. In the future, systematic variation of MO compositions and structures is expected to enable tailored interfacial charge transfer and extraction, thereby providing a route to optimization of PEC performance characteristics. While the focus of this initial study was on $\text{BiVO}_4/\text{WO}_3$ nanocomposites, the generality of this facile method for the assembly of preformed building blocks, which avoids tedious growth optimization and long preparation times, will enable access to a wide range of tailored heterojunctions.

■ ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.nanolett.5b03871.

Experimental details, TEM and SEM images, XRD patterns, EDS, XPS and Raman spectra, absorption spectra, Tauc plots, and J – E curves (PDF)

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Author Contributions

A.L. and R.B. conceived this study. A.L. synthesized and characterized the materials, including their photoelectrochemical behavior. J.K.C., L.H.H., and I.D.S. designed and carried out the carrier dynamics studies. T.M. performed the elemental analysis of the nanocrystals in solution and of films. All authors contributed to write the manuscript.

Notes

The authors declare no competing financial interest.

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